

## CORRECTION

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## Correction: Mixed H<sub>2</sub>O/H<sub>2</sub> plasma-induced redox reactions of thin uranium oxide films under UHV conditions

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Correction for 'Mixed H<sub>2</sub>O/H<sub>2</sub> plasma-induced redox reactions of thin uranium oxide films under UHV conditions' by Ghada El Jamal *et al.*, *Dalton Trans.*, 2021, DOI: 10.1039/d1dt01020d.

The authors regret an error in the surname of one of the authors, Lukáš Horák, in the original manuscript. In addition, the previous corresponding author Ghada El Jamal has now moved on from her position at KTH Royal Institute of Technology and so the corresponding author for this article has been changed to Mats Jonsson. The corrected list of authors and affiliations for this paper is as shown above.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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